

# Ion Bombardment Treatments for Metallic and Polymeric Bio-medical Materials

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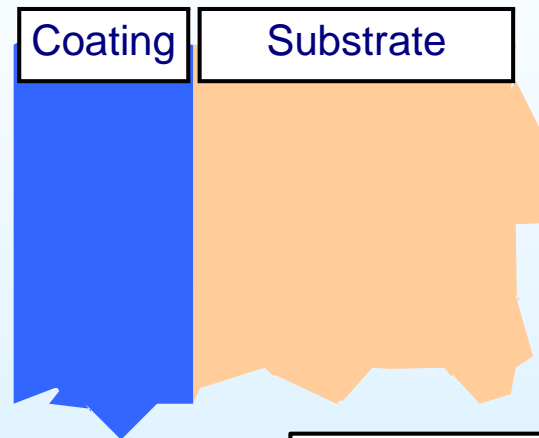
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# PRESENTATION

- 1 Ion implantation in the frame of advanced surface treatments**
- 2 Ion implantation treatment of metal alloys**
- 3 Ion implantation treatment of polymers**
- 4 Conclusions on bio-medical applications**

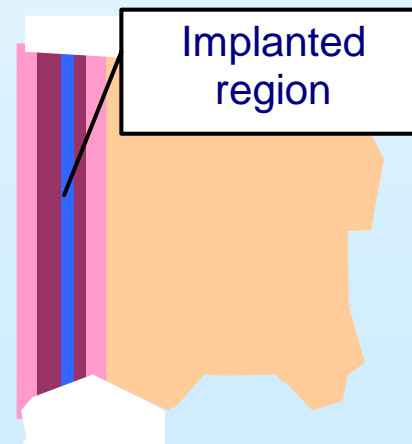
## TREATMENT STRATEGIES

### COATINGS



Coatings always change the dimensions of the pieces and have an abrupt transition

### ION IMPLANTATION



Ion implantation does not change dimensions and has a smooth transition to the substrate

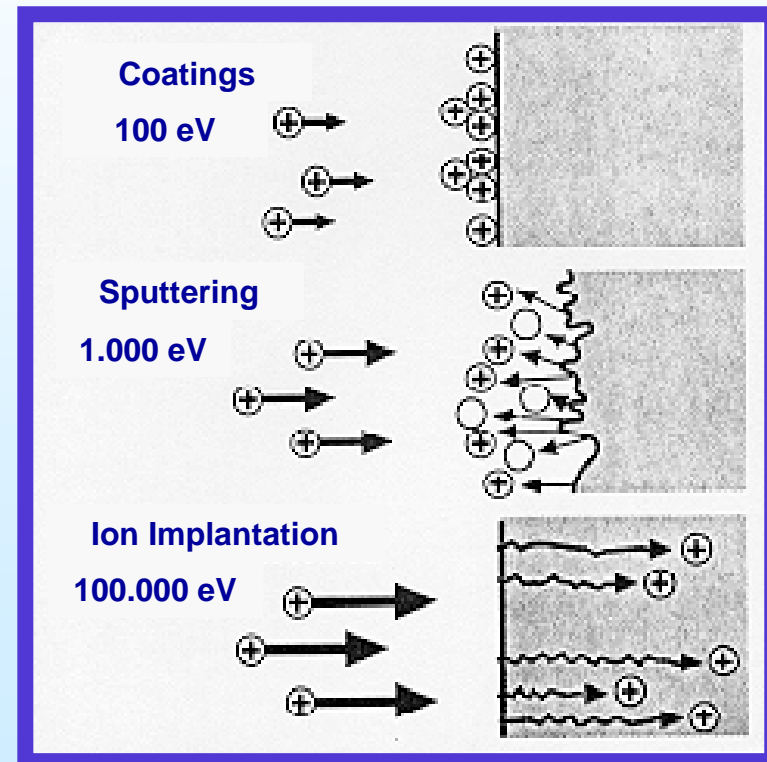
## EFFECTS OF ION BOMBARDMENT

**Ion Implantation is a ballistic treatment.**

**Depending on the bombardment energy, the dominant effect on the surface can be very different:**

- **Coatings ( $E < 100 \text{ eV}$ )**
- **Sputtering ( $100 \text{ eV} < E < 1000 \text{ eV}$ )**
- **Implantation ( $E > 10.000 \text{ eV}$ )**

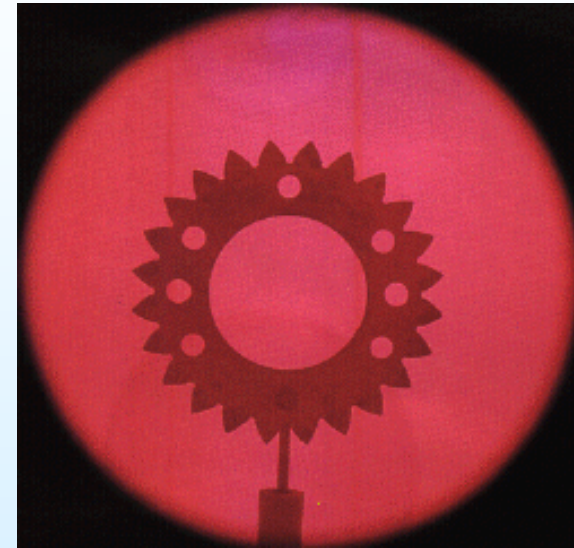
**Typical energies for Ion Implantation industrial surface treatment are between 10.000 eV and 200.000 eV**



## ION BOMBARDMENT STRATEGIES



**ION BEAM IMPLANTATION (II)**

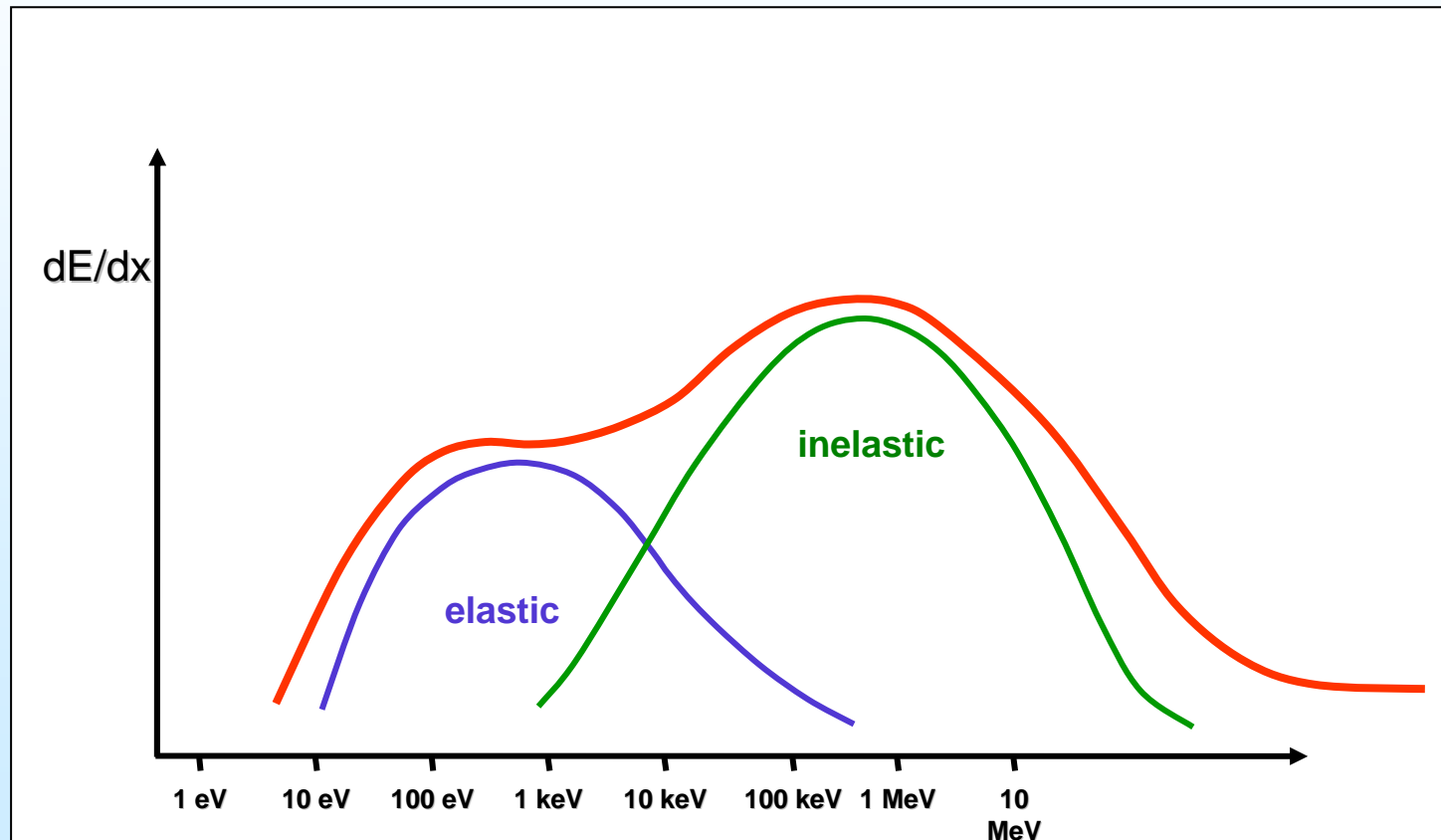


**PLASMA IMMERSION IMPLANTATION (PI<sup>3</sup>)**

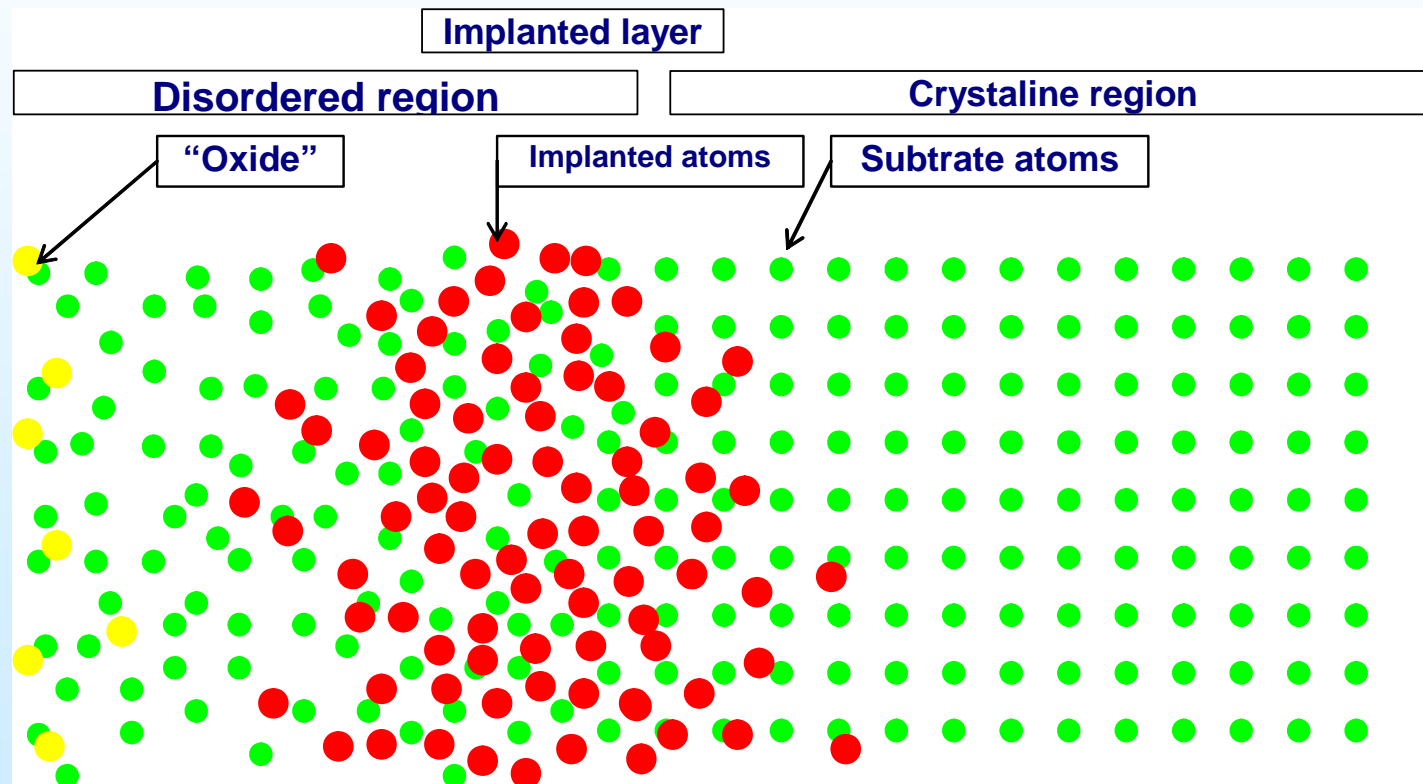
**In all cases, the relevant parameters are:**

- **Ion(s) to be implanted**
- **Energy**
- **Dose**

## STOPPING POWER



## ION IMPLANTATION RESULT

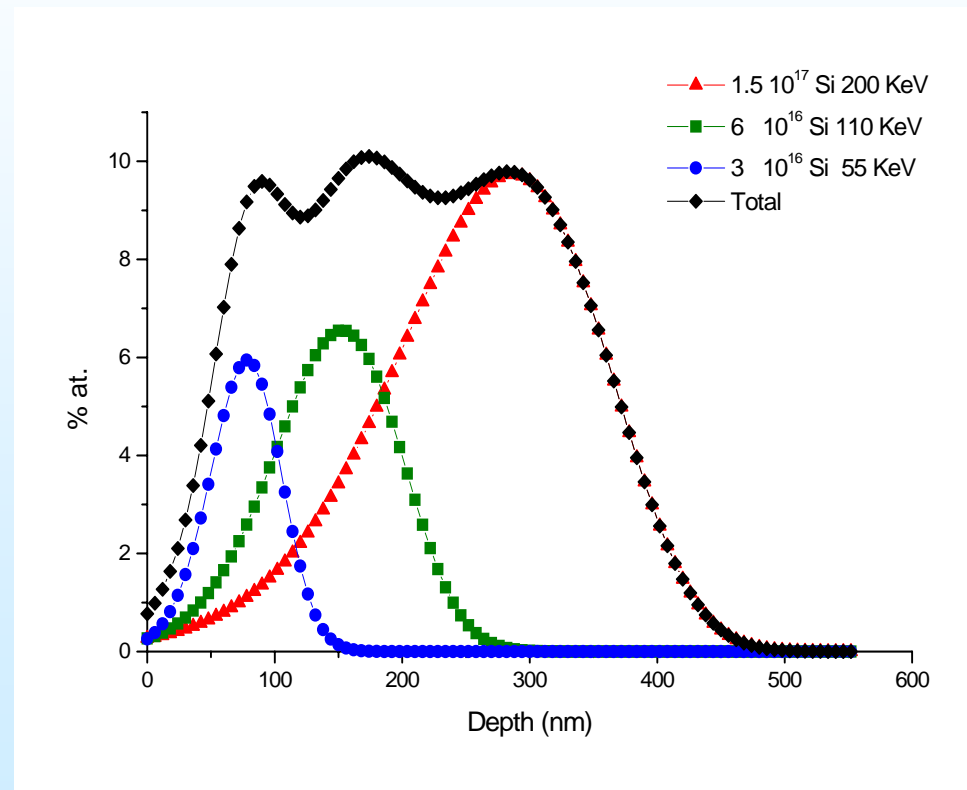


## SIMULATION OF THE ION IMPLANTATION RESULT

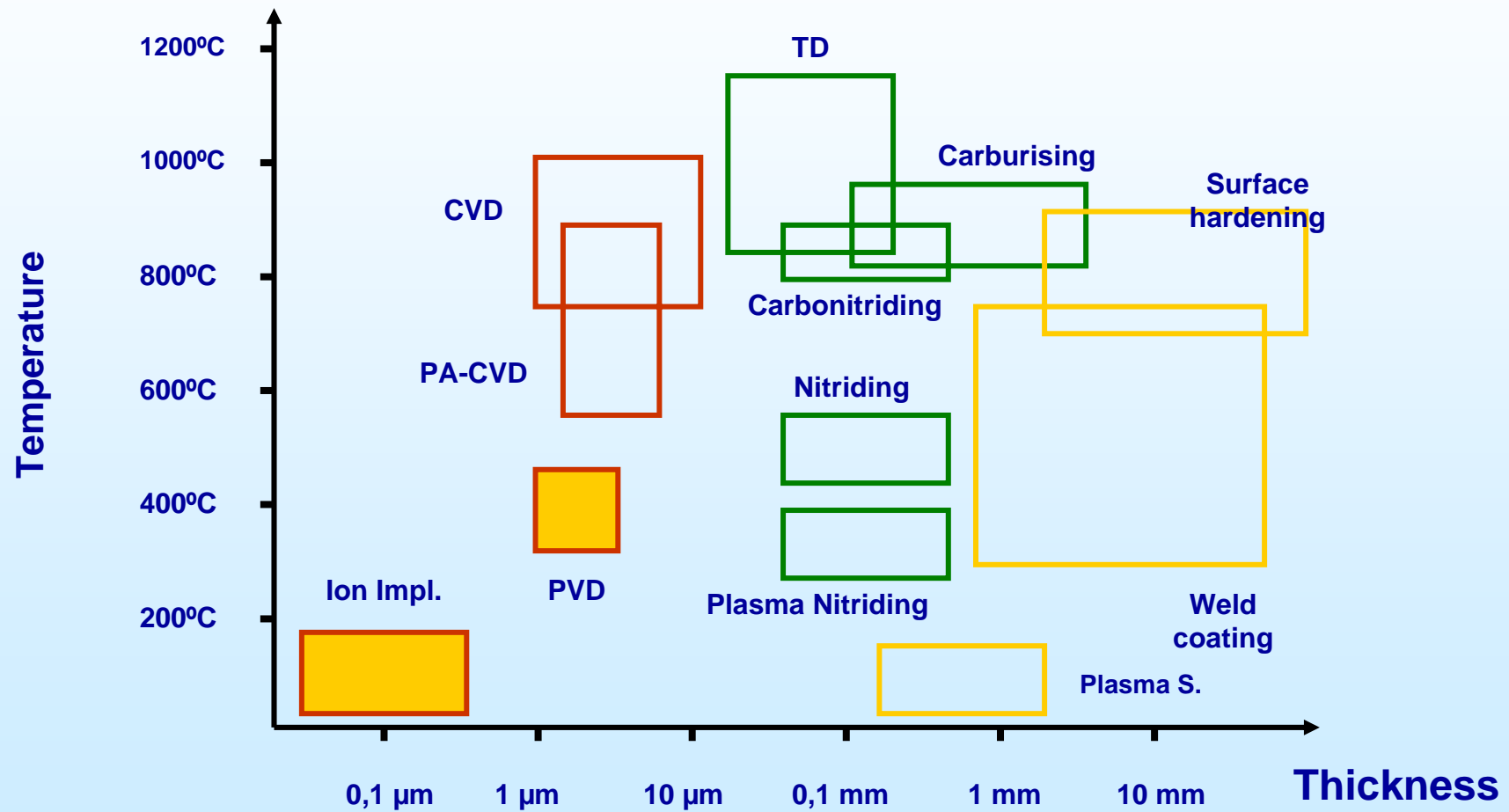
Range and distribution of implanted ions can be calculated by using TRIM or PROFILE codes.

Codes help to:

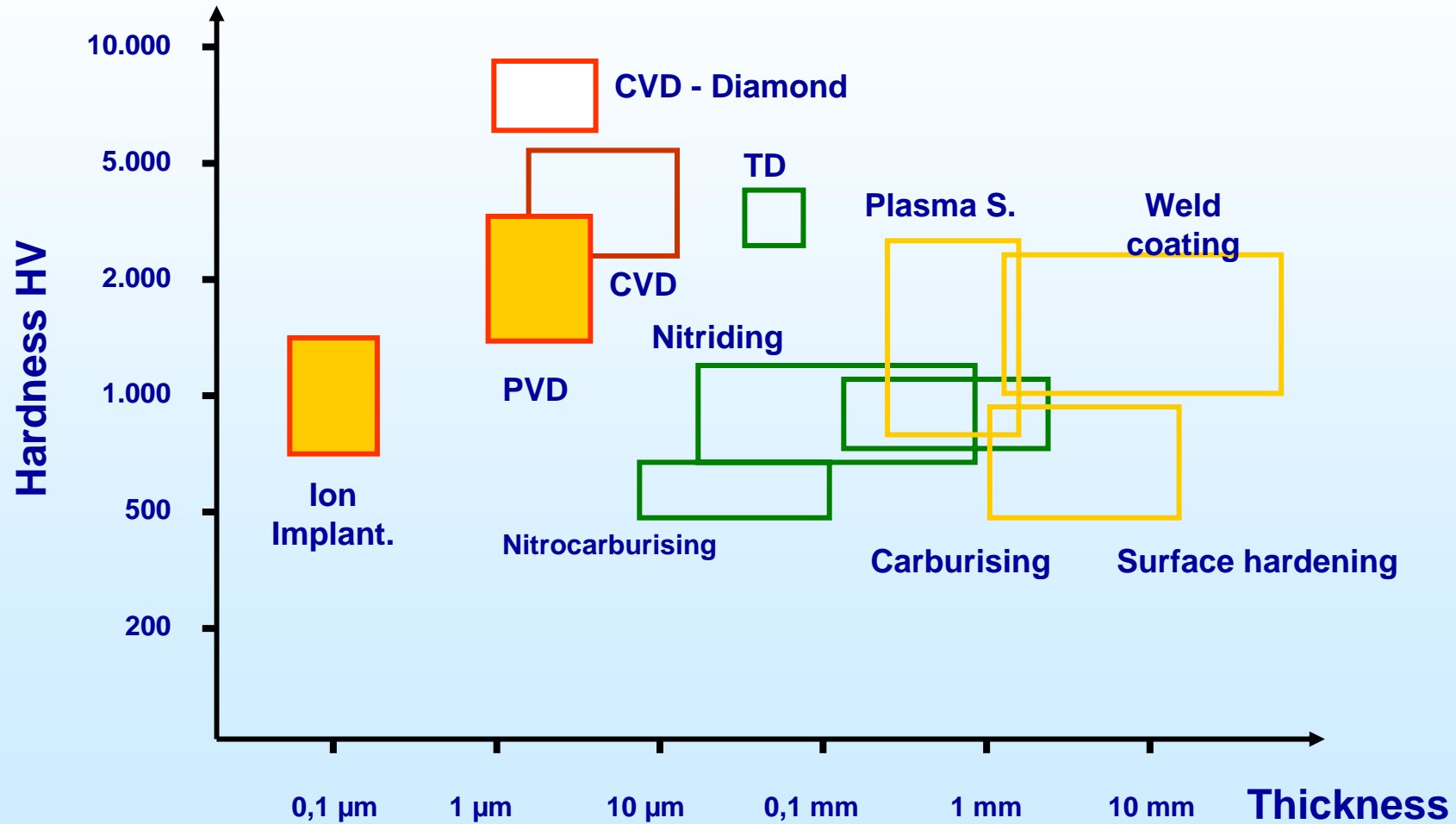
- design the implantation
- design co-implantations
- estimate saturation limits
- estimate other effects:
  - sputtering
  - ionization...



## TEMPERATURE vs. THICKNESS



## HARDNESS vs. THICKNESS

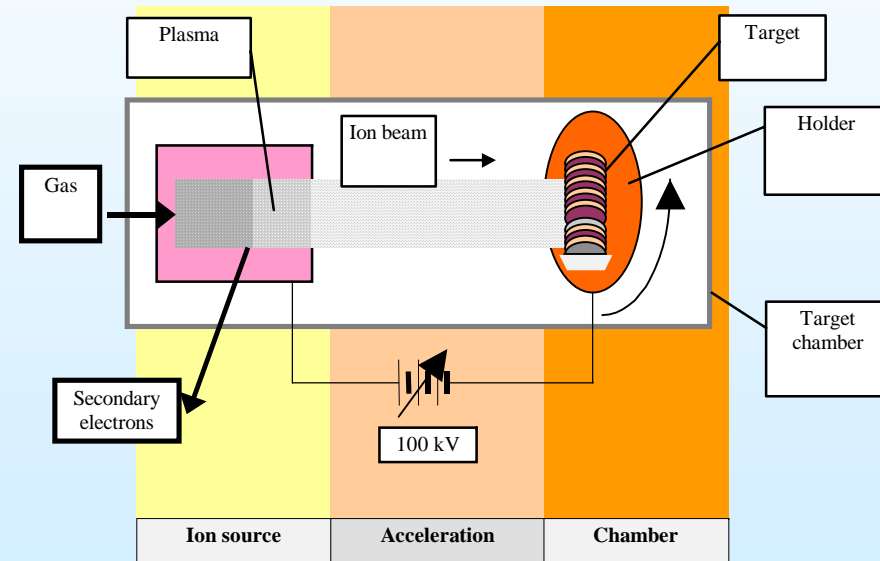


## NO MASS SEPARATION INDUSTRIAL ION IMPLANTER

For Nitrogen or other gas implantations  
it is enough to have:

- Gas ion source
- One acceleration step (100 keV)
- A target chamber with mechanical scanning

Again, the equipment operates at high  
vacuum ( $10^{-6}$  mbar)



## NO MASS SEPARATION INDUSTRIAL ION IMPLANTER

### TECVAC 223 Implanter

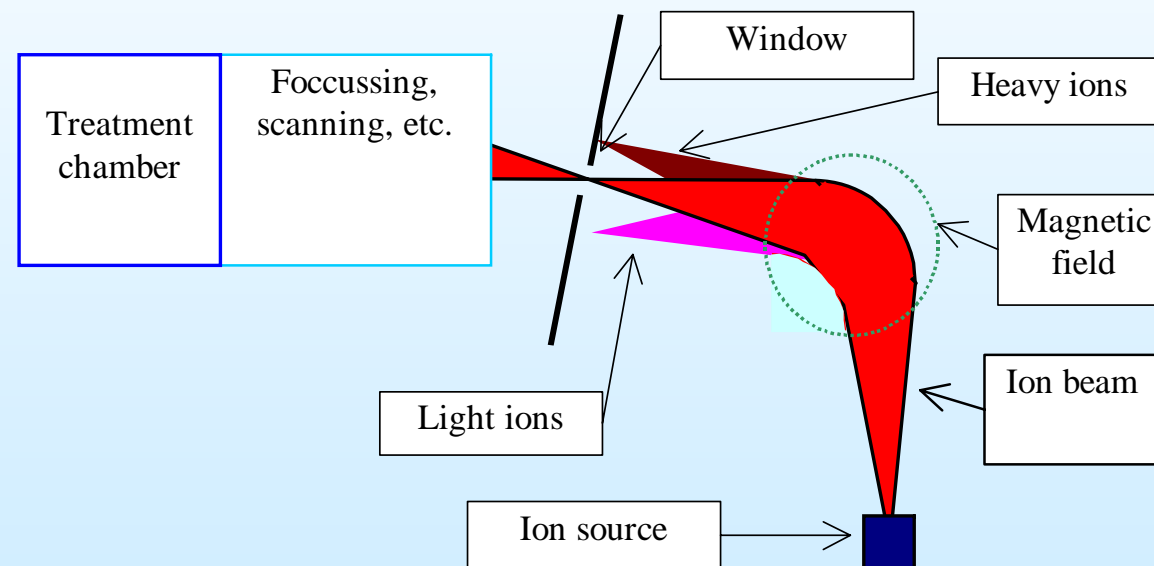
- Gas ion source
- No mass separation
- Beam intensities up to 3 mA
- Energies up to 100 keV
- Turbomolecular vacuum
- 2 axis mechanical scanning
- Automated control



## MASS SEPARATION INDUSTRIAL ION IMPLANTER

**For all species  
implantation, a mass  
separation system is  
needed.**

That lead to more  
complex and expensive  
equipment.



## MASS SEPARATION INDUSTRIAL ION IMPLANTER

### WHICKHAM IBS

### AIN - ion implanter

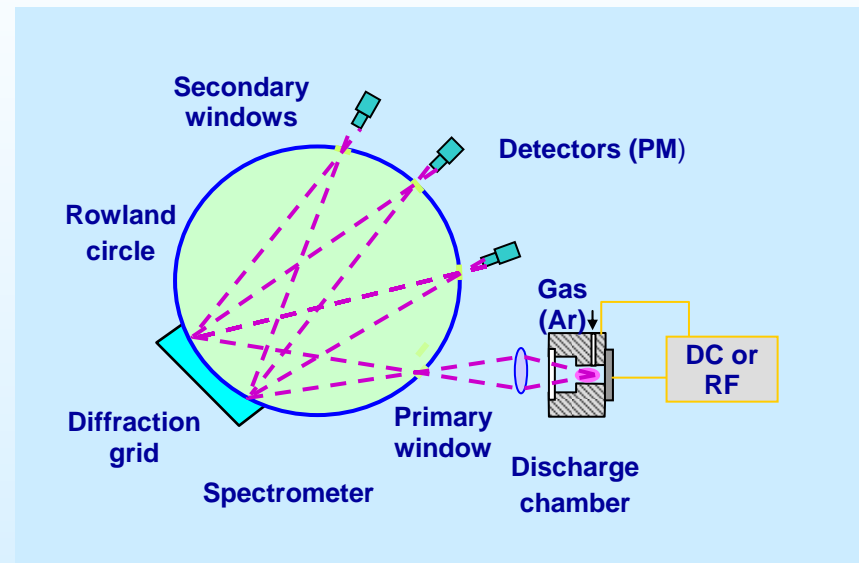
- Freeman ion source
- Mass separation
- Beam currents up to 5 mA
- Beam energy up to 200 keV
- Cryogenic vacuum
- 5 axis mechanical scanning
- Automated control



## TYPICAL ELEMENTS TO BE IMPLANTED

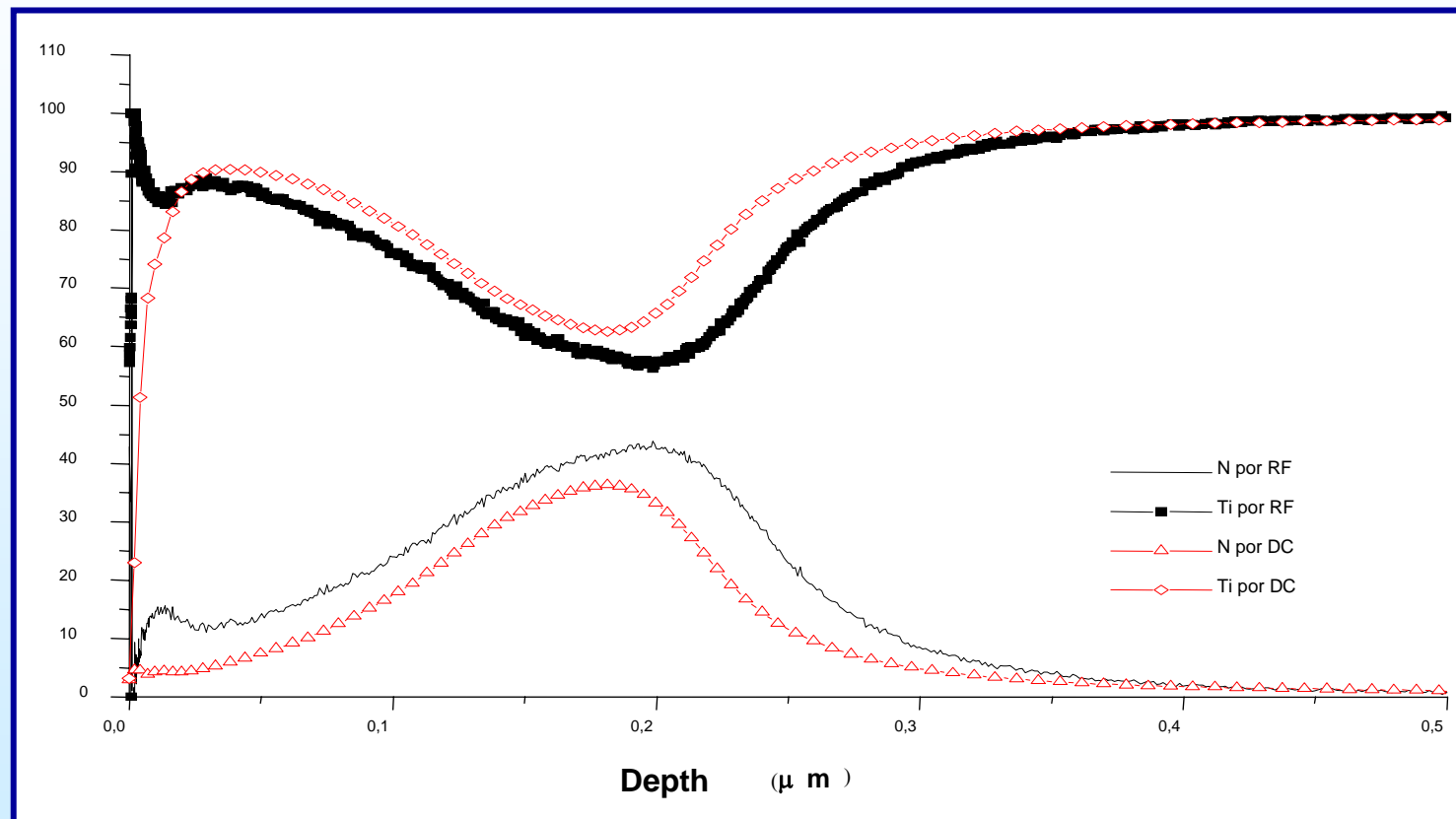
H 1																	He 2	
Li 3	Be 4											B 5	C 6	N 7	O 8	F 9	Ne 10	
Na 11	Mg 12											Al 13	Si 14	P 15	S 16	Cl 17	Ar 18	
K 19	Ca 20	Sc 21	Ti 22	V 23	Cr 24	Mn 25	Fe 26	Co 27	Ni 28	Cu 29	Zn 30	Ga 31	Ge 32	As 33	Se 34	Br 35	Kr 36	
Rb 37	Sr 38	Y 39	Zr 40	Nb 41	Mo 42	Tc 43	Ru 44	Rh 45	Pd 46	Ag 47	Cd 48	In 49	Sn 50	Sb 51	Te 52	I 53	Xe 54	
Cs 55	Ba 56	La 57	Hf 72	Ta 73	W 74	Re 75	Os 76	Ir 77	Pt 78	Au 79	Hg 80	Tl 81	Pb 82	Bi 83	Po 84	At 85	Rn 86	
Fr 87	Ra 88	Ac 89																
			Ce 58	Pr 59	Nd 60	Pm 61	Sm 62	Eu 63	Gd 64	Tb 65	Dy 66	Ho 67	Er 68	Tm 69	Yb 70	Lu 71		
			Th 90	Pa 91	U 92	Np 93	Pu 94	Am 95	Cm 96	Bk 97	Cf 98	Es 99	Fm 100	Md 101	No 102	Lr 103		

## PRACTICAL SURFACE ANALYSIS: GD-OES



**Glow Discharge Optical Emission Spectroscopy (GD-OES) allows to obtain precision quantitative composition profiles in few minutes. No UHV is required. Just well polished flat implanted samples.**

## PRACTICAL SURFACE ANALYSIS: GD-OES



GD-OES analysis of a Ti sample implanted with  $8 \cdot 10^{17} \text{ N}_2^+$

## EFFECTS ON THE IMPLANTED MATERIALS

### INCREASE OF HARDNESS

- Precipitation of nitrides, carbides, etc.
- New alloys formation
- *Cross-linking* of polymers

### BETTER TRIBOLOGICAL BEHAVIOUR

- More homogeneous / coherent oxide layers

### RESISTANCE TO ROLLING FATIGUE

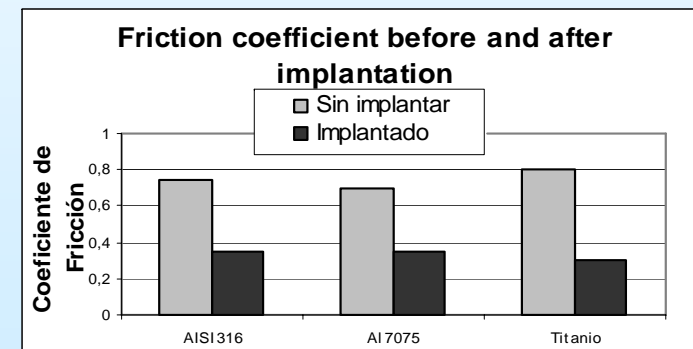
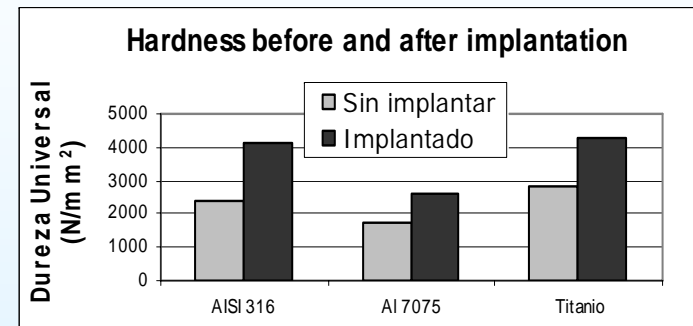
- Compressive tensions at the surface

### CORROSION RESISTANCE

- New alloys with better resistance
- Better adhered and compact oxide layers

### OXIDACION RESISTANCE

- Surface doping with lanthanide elements



R. Rodríguez, A. Sanz, A. Medrano and J.A. García-Lorente.  
**Tribological properties of ion implanted Aluminium alloys.**  
*Vacuum* **52** (1999), 187.

## ELEMENTS THAT CAN BE IMPROVED BY NITROGEN IMPLANTATION

H 1																	He 2																												
Li 3	Be 4											B 5	C 6	N 7	O 8	F 9	Ne 10																												
Na 11	Mg 12															Al 13	Si 14	P 15	S 16	Cl 17	Ar 18																								
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Rb 37	Sr 38	Y 39	Zr 40	Nb 41	Mo 42	Tc 43	Ru 44	Rh 45	Pd 46	Ag 47	Cd 48	In 49	Sn 50	Sb 51	Te 52	I 53	Xe 54																												
Cs 55	Ba 56	La 57	Hf 72	Ta 73	W 74	Re 75	Os 76	Ir 77	Pt 78	Au 79	Hg 80	Tl 81	Pb 82	Bi 83	Po 84	At 85	Rn 86																												
Fr 87	Ra 88	Ac 89																																											
<table border="1"> <tbody> <tr> <td>Ce 58</td> <td>Pr 59</td> <td>Nd 60</td> <td>Pm 61</td> <td>Sm 62</td> <td>Eu 63</td> <td>Gd 64</td> <td>Tb 65</td> <td>Dy 66</td> <td>Ho 67</td> <td>Er 68</td> <td>Tm 69</td> <td>Yb 70</td> <td>Lu 71</td> </tr> <tr> <td>Th 90</td> <td>Pa 91</td> <td>U 92</td> <td>Np 93</td> <td>Pu 94</td> <td>Am 95</td> <td>Cm 96</td> <td>Bk 97</td> <td>Cf 98</td> <td>Es 99</td> <td>Fm 100</td> <td>Md 101</td> <td>No 102</td> <td>Lr 103</td> </tr> </tbody> </table>																		Ce 58	Pr 59	Nd 60	Pm 61	Sm 62	Eu 63	Gd 64	Tb 65	Dy 66	Ho 67	Er 68	Tm 69	Yb 70	Lu 71	Th 90	Pa 91	U 92	Np 93	Pu 94	Am 95	Cm 96	Bk 97	Cf 98	Es 99	Fm 100	Md 101	No 102	Lr 103
Ce 58	Pr 59	Nd 60	Pm 61	Sm 62	Eu 63	Gd 64	Tb 65	Dy 66	Ho 67	Er 68	Tm 69	Yb 70	Lu 71																																
Th 90	Pa 91	U 92	Np 93	Pu 94	Am 95	Cm 96	Bk 97	Cf 98	Es 99	Fm 100	Md 101	No 102	Lr 103																																

## SURFACE MECHANICAL PROPERTIES: HU and E



Universal Hardness (HU) can be measured from 1mN, till 1000 mN of maximum load by using a **Fischeroscope** microindentation equipment. At 2mN, the indentation depth in metals is less than 0,2 microns

Elastic and plastic hardness as well as elastic modulus can be obtained from the load – unload curves.

# UNIVERSAL HARDNESS TESTS ON IMPLANTED SURFACES

## LOW LOADS:

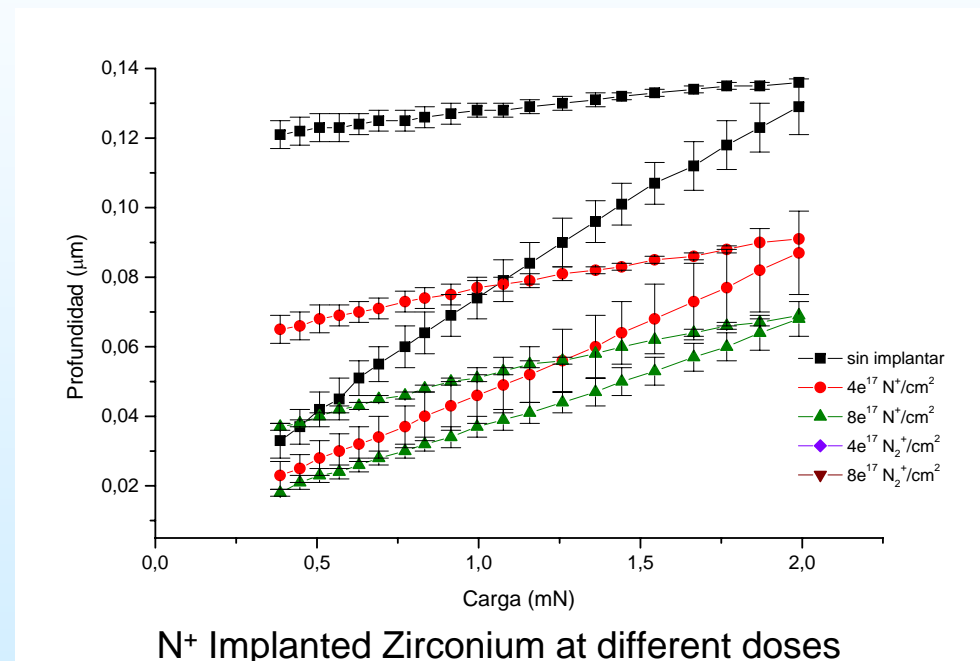
Low indentation loads are needed because the implanted region is thinner than few tenths of micron.

## DEFFECTLESS SURFACES:

Hardness tests can be carried out only on mirror polished surfaces.

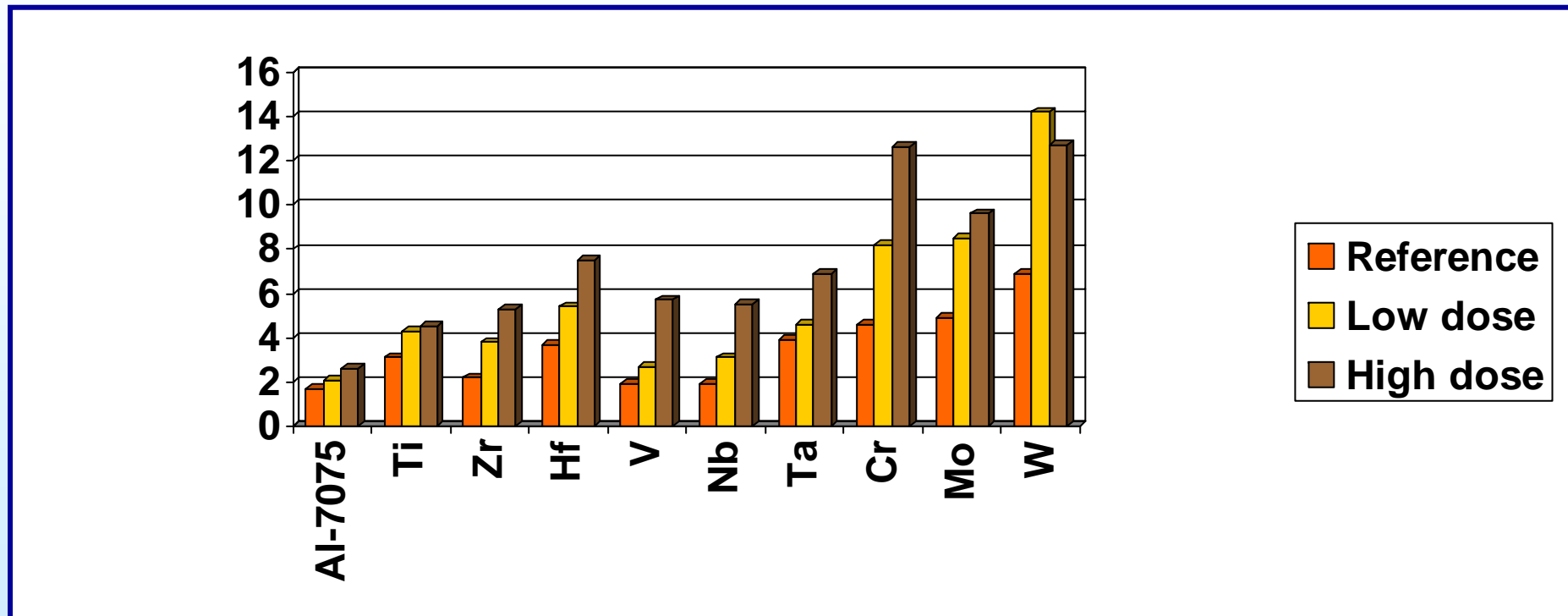
## BETTER ON SOFT METALS:

Changes in hardness are more visible on soft metals.



J. A. García, A. Guette, A. Medrano, C. Labrugere, M. Rico, M. Lahaye, R. Sánchez, R. Martínez and R. J. Rodríguez: **Nitrogen ion implantation on Group IV metals: chemical, structural and tribological study**, Vacuum **64**, 343 (2002).

## HARDNESS (GPa) OF NITROGEN IMPLANTED METALS



J. A. García, A. Guette, A. Medrano, C. Labrugere, M. Rico, M. Lahaye, R. Sánchez, R. Martínez and R. J. Rodríguez

**Nitrogen ion implantation on Group IV metals: Chemical, structural and tribological study.** *Vacuum* **64** (2002), 343.

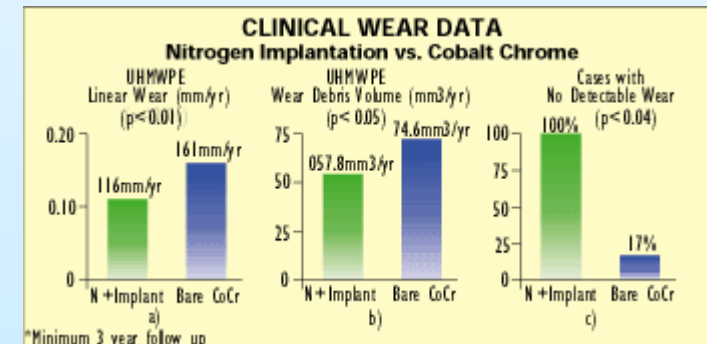
J. A. García, R. J. Rodríguez, A. Medrano, R. Sánchez, M. Rico, R. Martínez, B. Lerga, C. Labrugere, M. Lahaye, and A. Guette

**Study of the tribological modifications induced by nitrogen implantation on group V metals.** *Surface and Coatings Technology* **158-159** (2002), 653.

R. Martínez, J. A. García, R. J. Rodríguez, B. Lerga, C. Labrugere, M. Lahaye, and A. Guette

**Study of the tribological modifications induced by nitrogen implantation on group VI: Cr, Mo and W.** *Surface and Coatings Technology* **174-175** (2003), 1253.

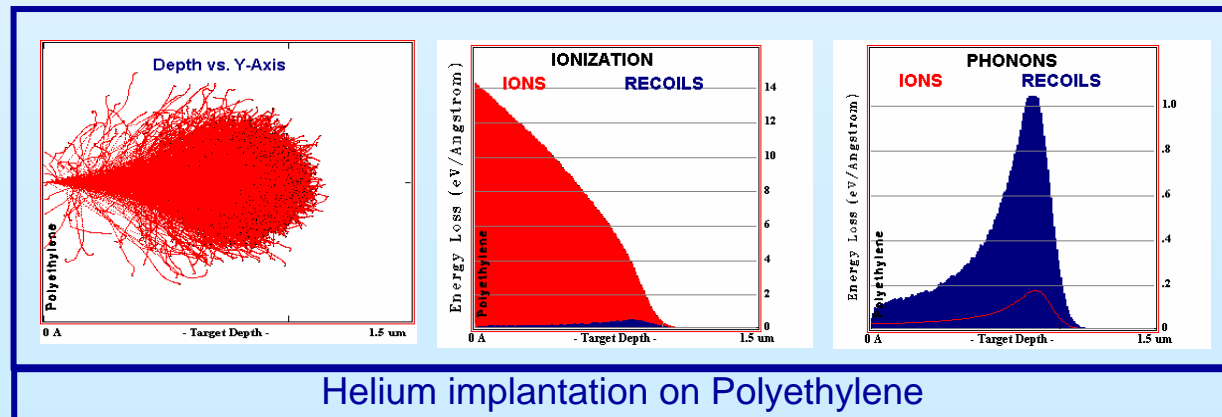
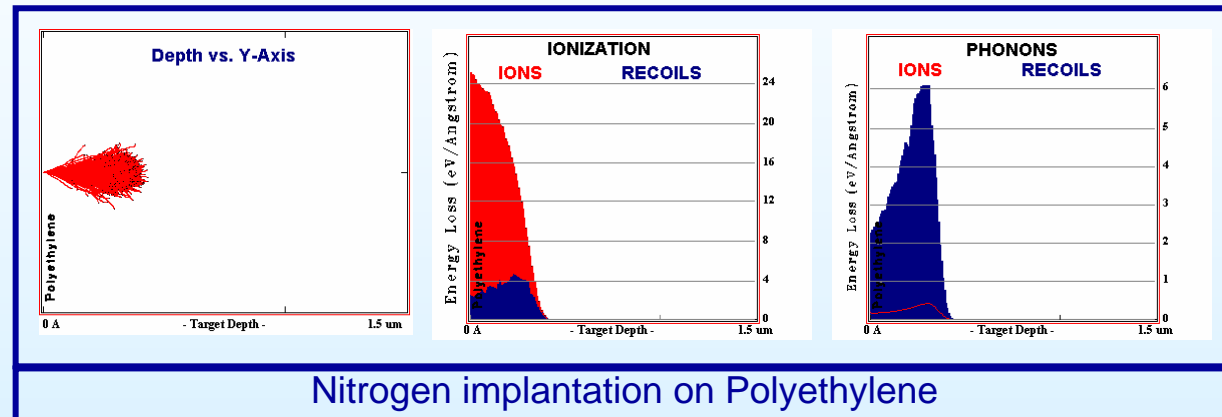
# APPLICATIONS FOR HIP AND KNEE PROSTHESIS



## ION IMPLANTATION ON POLYMERS

The main effect of ion implantation on polymers is the increase in hardness due to the cross linking of polymer chains because the ionisation produced by ion bombardment.

The effect is more intense for light and energetic ions because they loss energy preferentially by ionisation (inelastic stopping power), have minor chain breakage effects (elastic stopping power) and goes deeper.



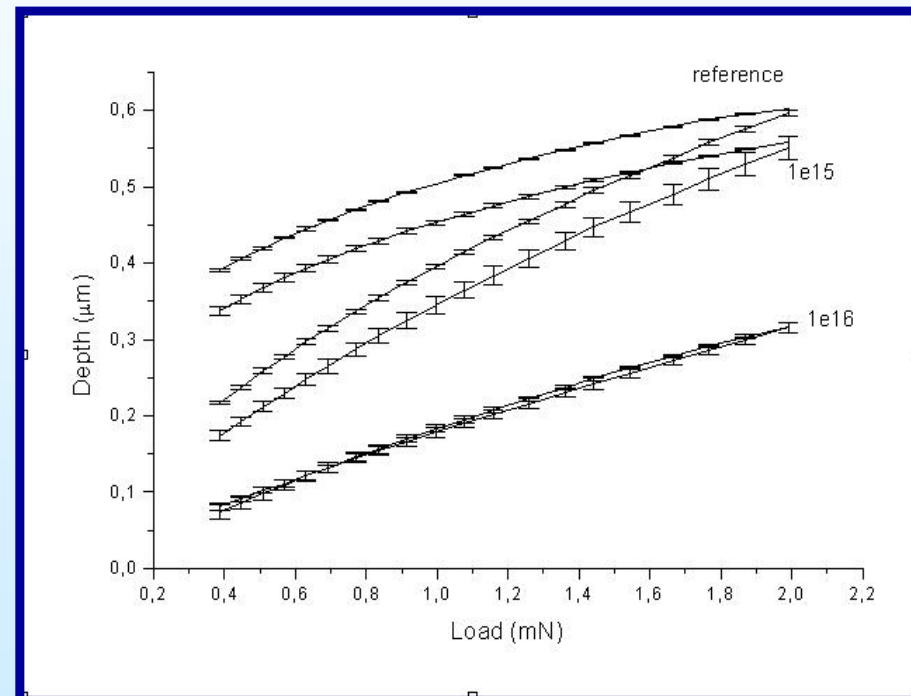
## INCREASE OF POLYMER HARDNESS BY HIDROGEN IMPLANTATION

### LOW DOSE IMPLANTATION ON POLYCARBONATE:

A low dose implantation is enough to produce a dramatic increase of hardness.

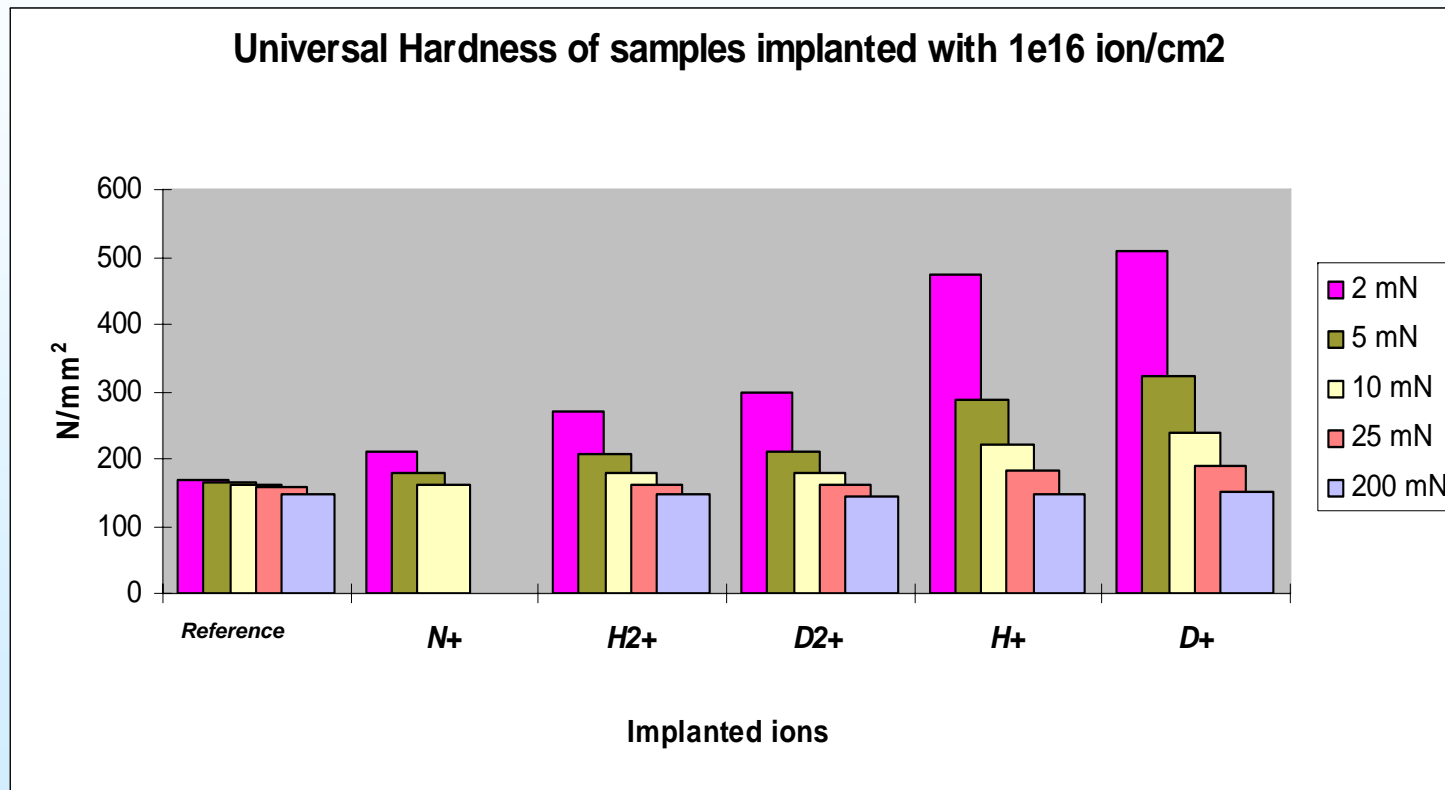
### HU vs. HV:

Elastic recovery reach the 100% for a implanted surface. That would lead to an apparently infinite HV.



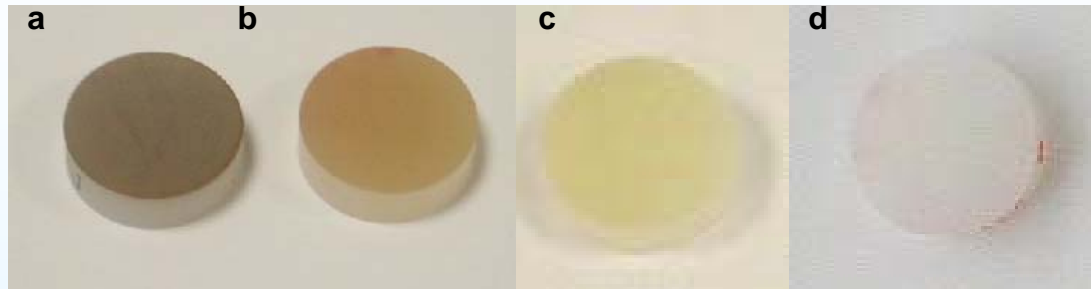
R. Rodríguez, J. A. García, R. Sánchez, A. Pérez, Blas Garrido and J. Morante:  
**Modification of surface mechanical properties of polycarbonate by ion implantation.**  
*Surface and Coatings Technology* **158-159** (2002), 636.

## ION IMPLANTATION OF POLYCARBONATE



R. Rodríguez, J. A. García, R. Sánchez, A. Pérez, Blas Garrido and J. Morante:  
**Modification of surface mechanical properties of polycarbonate by ion implantation.**  
*Surface and Coatings Technology* **158-159** (2002), 636.

## IMPLANTATION OF UHMWPE SAMPLES



### UHMWPE SAMPLES AFTER IMPLANTATION

- a) UHMWPE sample implanted with  $1 \times 10^{16}$  ions/cm<sup>2</sup> of N.
- b) UHMWPE sample implanted with  $5 \times 10^{15}$  ions/cm<sup>2</sup> of N.
- c) UHMWPE sample implanted with  $5 \times 10^{15}$  ions/cm<sup>2</sup> of He.
- d) Untreated UHMWPE sample.

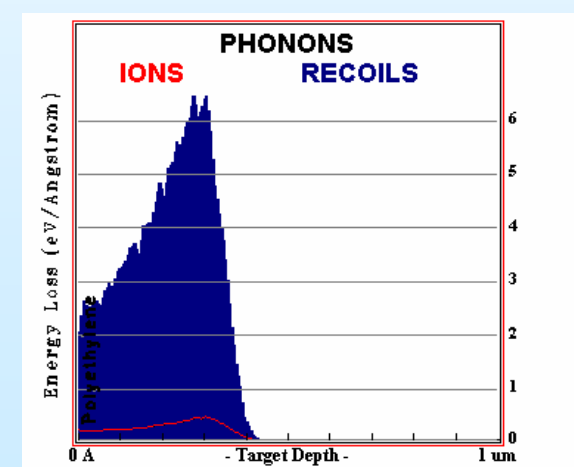
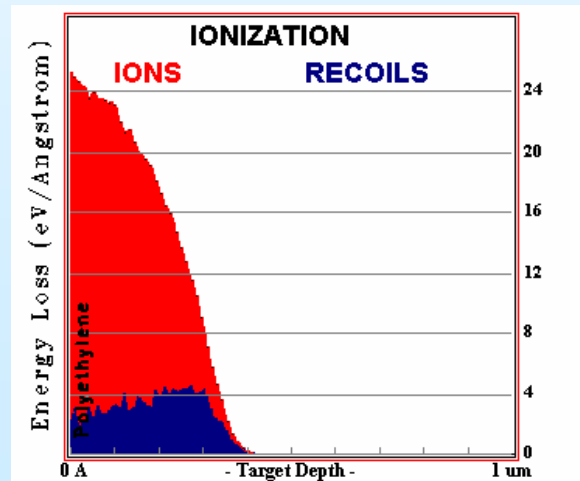
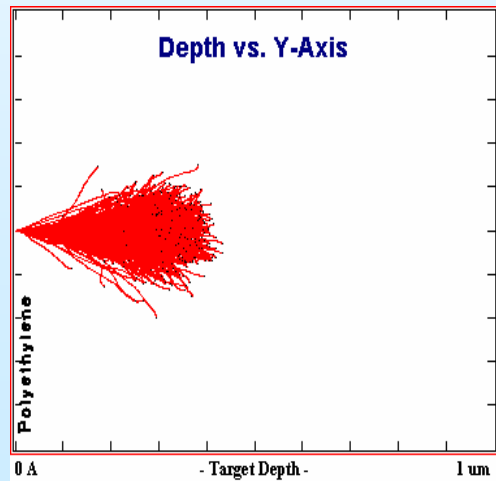
Visual inspection of samples after the implantation with different doses and ions shows that:

- After the treatments a change in the surface color was observed, the higher the dose the darker the color.
- Nitrogen implantation produced a darker surface than Helium.

## NITROGEN EFFECTS ON UHMWPE

The TRIM stopping power calculations shows that:

- The range of Nitrogen implantation on UHMWPE, at 90 keV, is about 400 nm.
- A **80,5%** of the bombardment energy is lost through inelastic mechanism and lead to ionization of the polymer chains.
- The other **19,5%** of the energy is lost through elastic mechanism, leading to chain breakdown.

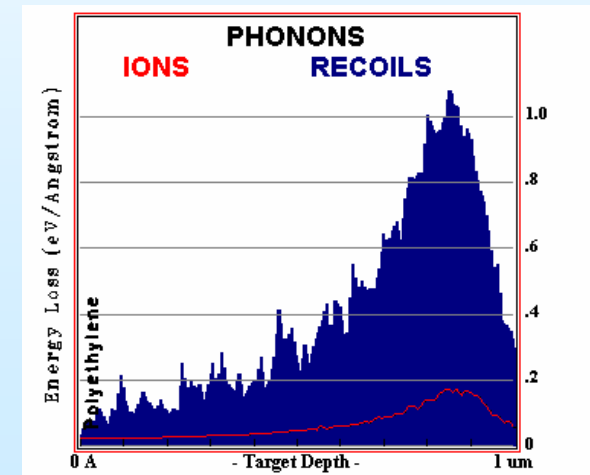
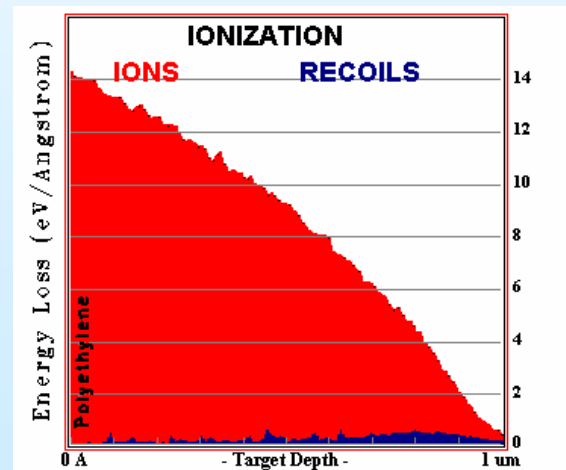
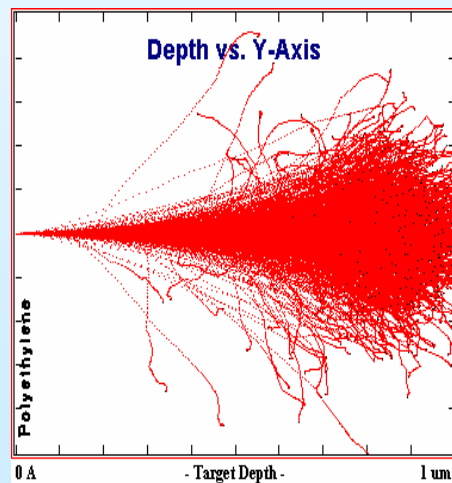


### TRIM CALCULATION OF THE NITROGEN RANGE ON UHMWPE AND ENERGY LOSS MECHANISMS

## HELIUM EFFECTS ON UHMWPE

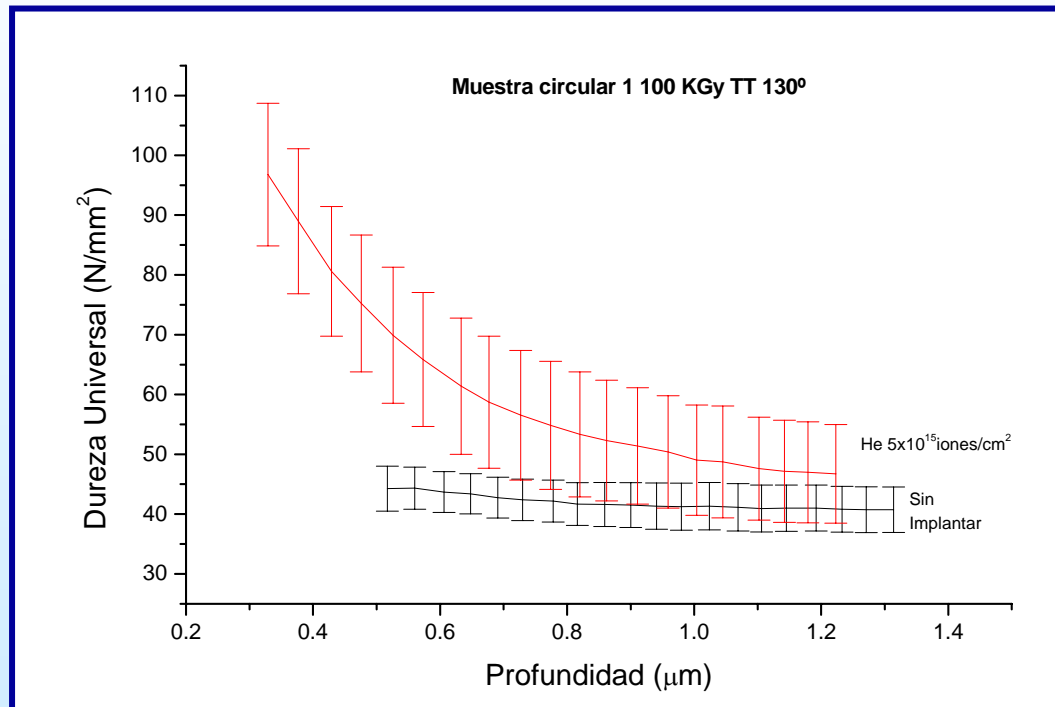
The TRIM stopping power calculations shows that:

- The range of Helium implantation on UHMWPE, at 90 keV, is about 1000 nm.
- A **94,5%** of the bombardment energy is lost through inelastic mechanism and lead to ionization of the polymer chains.
- The other **5,5%** of the energy is lost through elastic mechanism, leading to chain breakdown.



### TRIM CALCULATION OF THE HELIUM RANGE ON UHMWPE AND ENERGY LOSS MECHANISMS

## RESULTS OF INDENTENTION TESTS



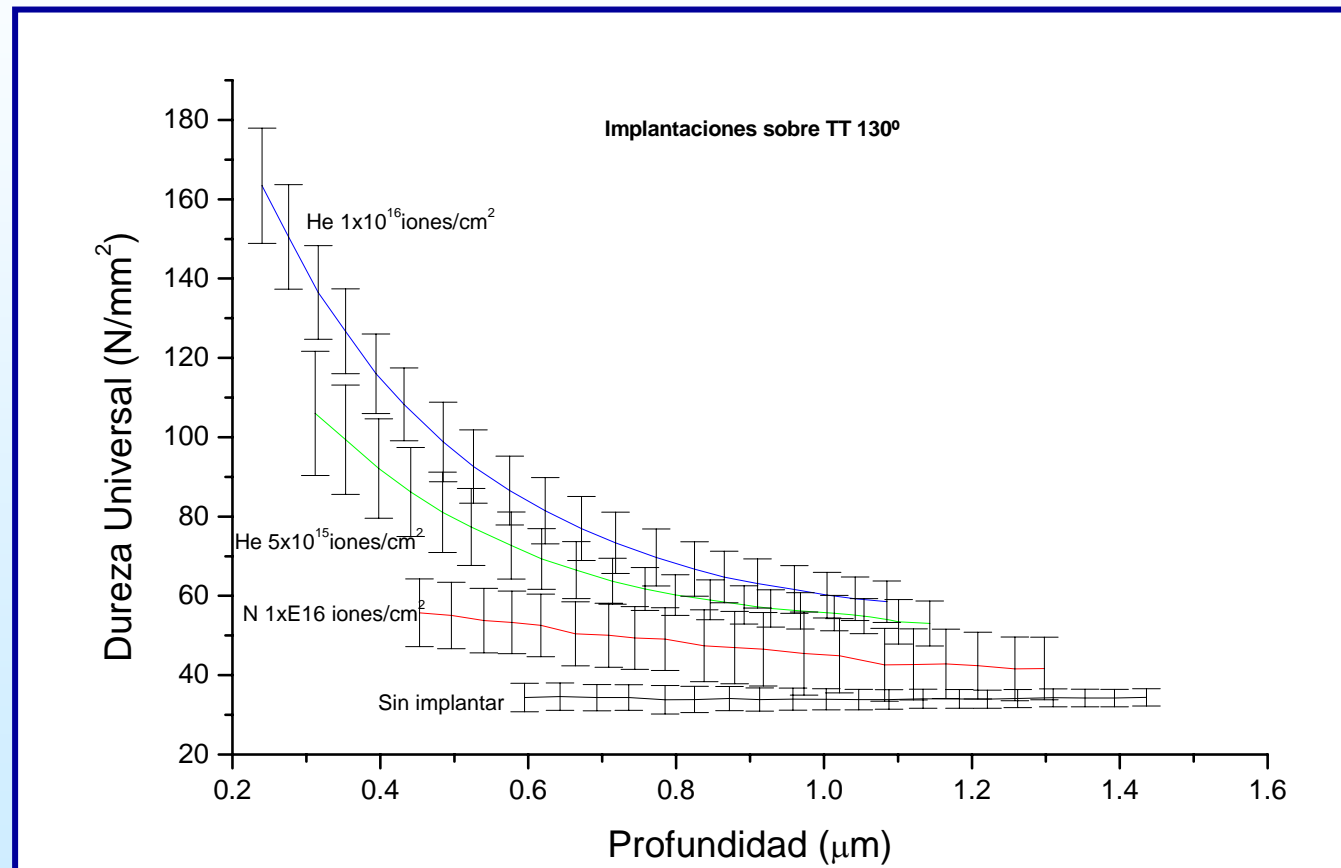
PROFILE OF HARDNESS vs. DEPTH FOR  
IMPLANTATION 4 AND UNTREATED SAMPLE

### UNIVERSAL HARDNESS IN (N/mm<sup>2</sup>)

SAMPLE	2 mN
UNTREATED	34 ± 2
IMPLANTATION 1 - N 5x10 <sup>15</sup>	43 ± 4
IMPLANTATION 2 - N 1x10 <sup>16</sup>	42 ± 8
IMPLANTATION 3 - He 5x10 <sup>15</sup>	53 ± 6
IMPLANTATION 4 - He 1x10 <sup>16</sup>	59 ± 5
IMPLANTATION 5 - He 2x10 <sup>16</sup>	40 ± 9

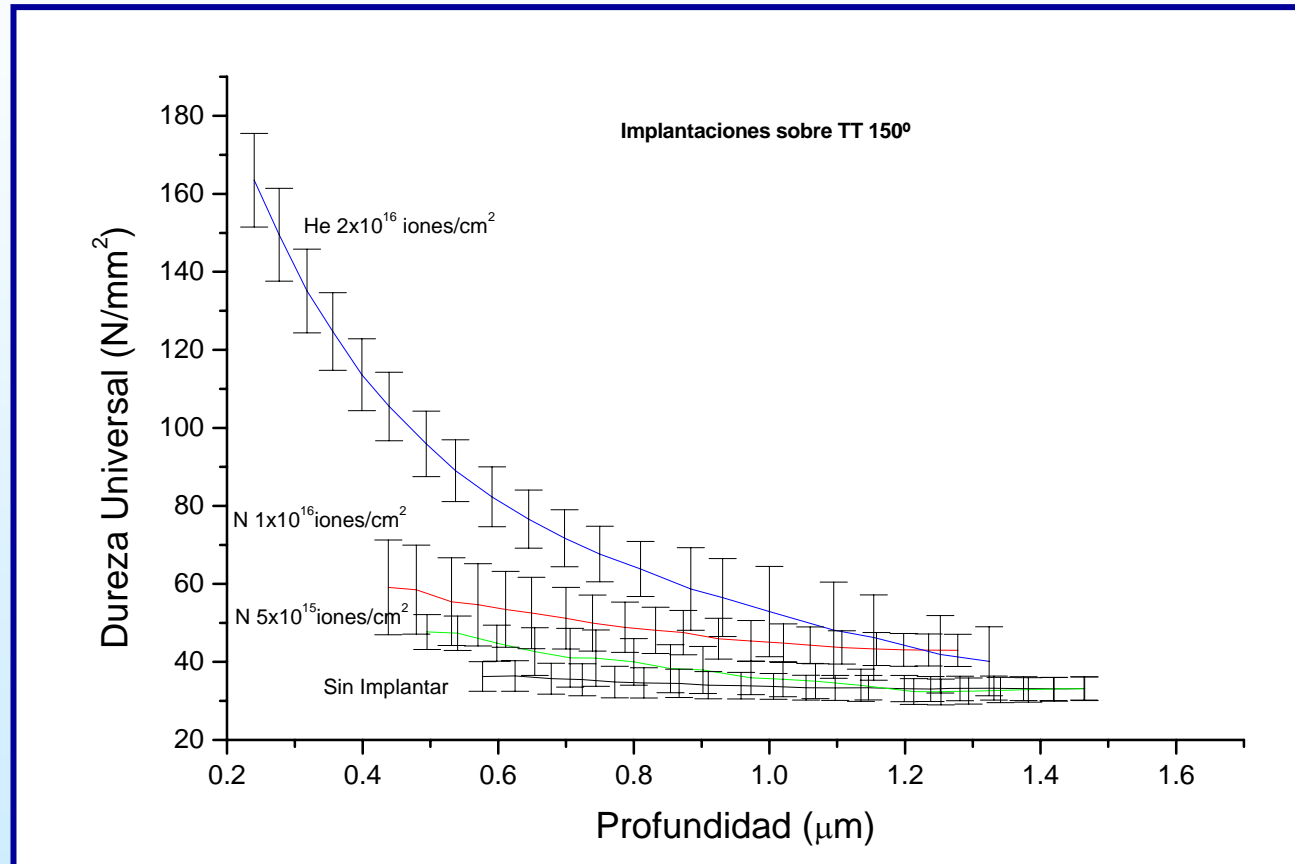
HU at 2mN OF FINAL LOAD

## RESULTS OF INDENTATION TESTS



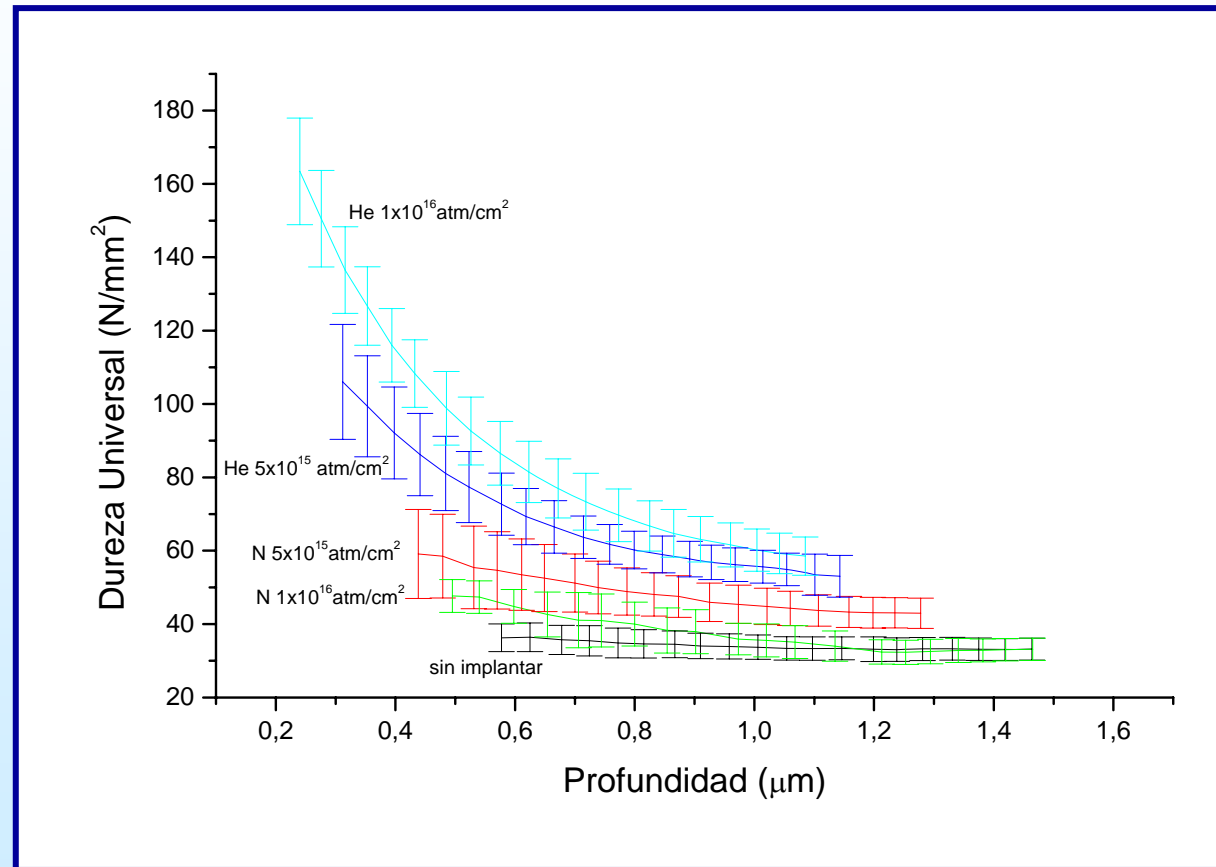
COMPARISON OF HARDNESS PROFILES OF THE IMPLANTATIONS CARRIED OUT ON UHMWPE SAMPLES WITH PRETREATMENT AT 130°C

## RESULTS OF INDENTATION TESTS



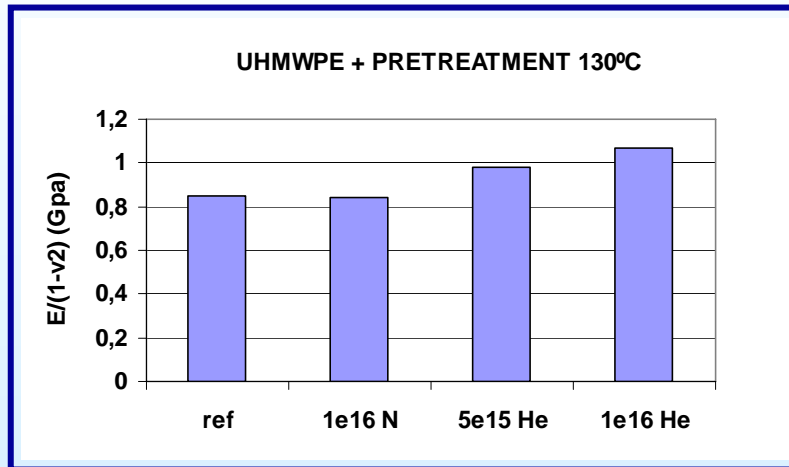
COMPARISON OF HARDNESS PROFILES OF THE IMPLANTATIONS CARRIED OUT ON UHMWPE SAMPLES WITH PRETREATMENT AT 150°C

## RESULTS OF INDENTENTION TESTS

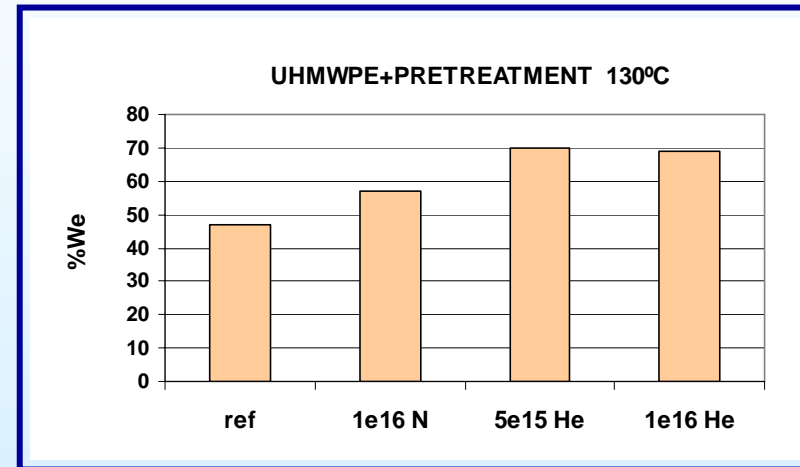


COMPARISON OF HARDNESS PROFILES OF THE IMPLANTATIONS WITH ALL THE DIFFERENT DOSES AND IONS

## ELASTIC MODULUS AND ELASTIC WORK



a



b

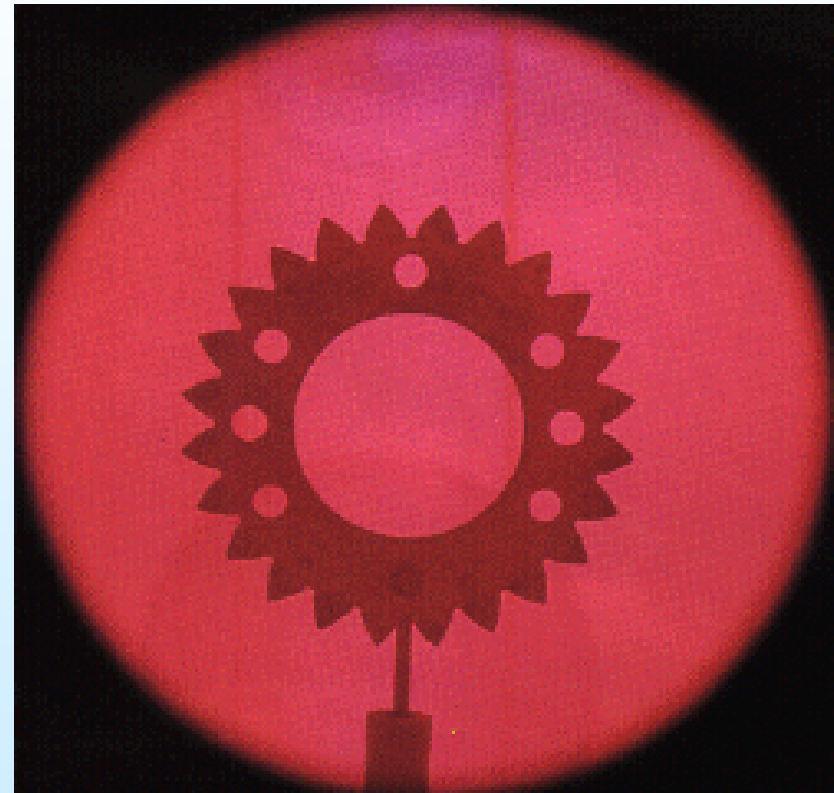
(a) ELASTIC MODULUS AND (b) % OF ELASTIC WORK OF THE IMPLANTED SAMPLES, MEASURED AT FINAL LOAD OF 2mN.

## PLASMA IMMERSION ION IMPLANTATION

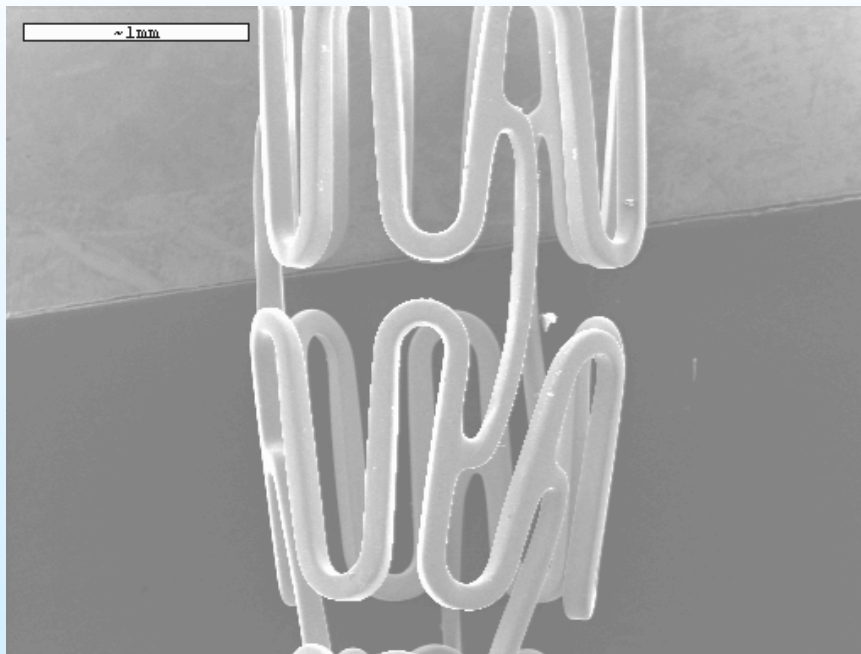
Plasma Immersion Ion Implantation (PI<sup>3</sup>) has been claimed as the future solution of the ion implantation problems (line-of-light process, sequential process...).

The no directional intense bombardment can increase the temperature. That would lead to a combined ballistic - diffusional process.

PI<sup>3</sup> is an excellent alternative to conventional processes for treating large series of small complex shape components like stents



## APPLICATIONS ON STENTS

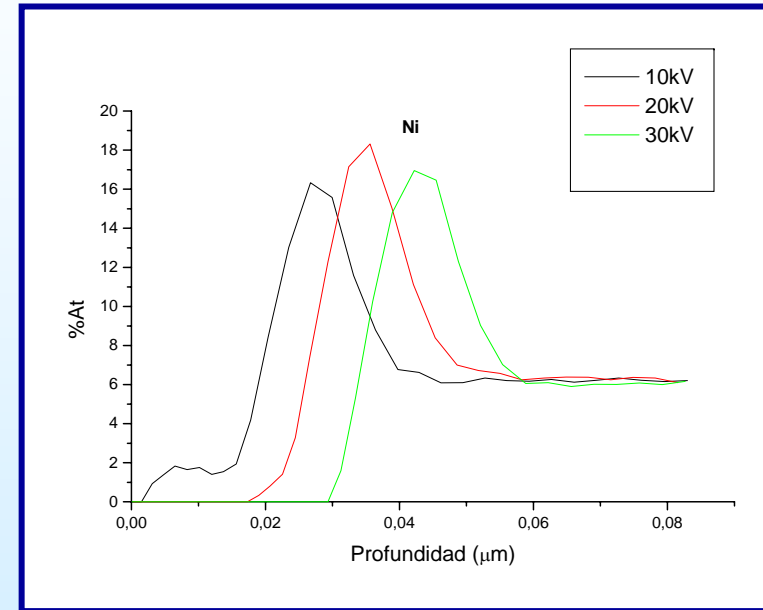
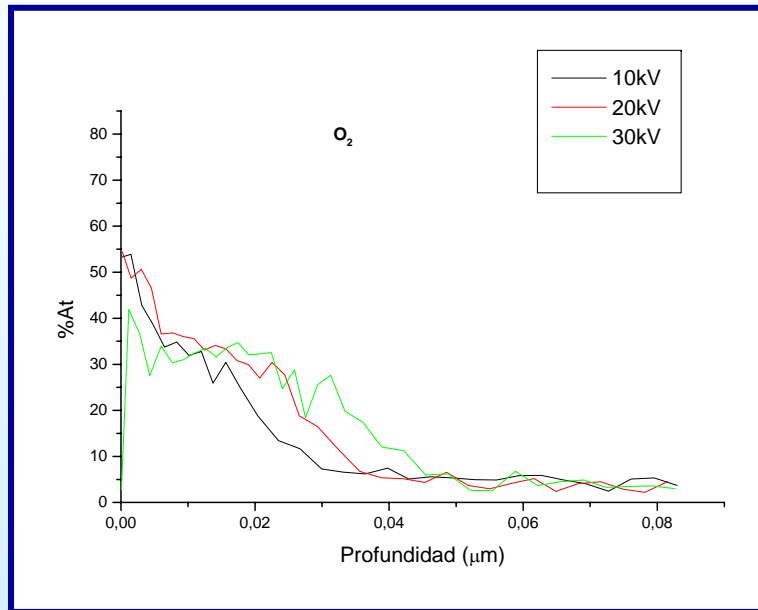


**Stents are being extensively employed in many surgical operations.**

**There are some concerns about the stability of stents that have to remain implanted in the human body. It is worth to mention the effects of metal ion migration (possible toxicity).**

**To prevent the migration of undesired ions, (e.g. Nickel) a possible technique is the creation of an oxide barrier. Ion implantation of Oxygen could be a good strategy, but the ordinary line-of-sight ion implantation process is not adequate to implant thousands of small components.**

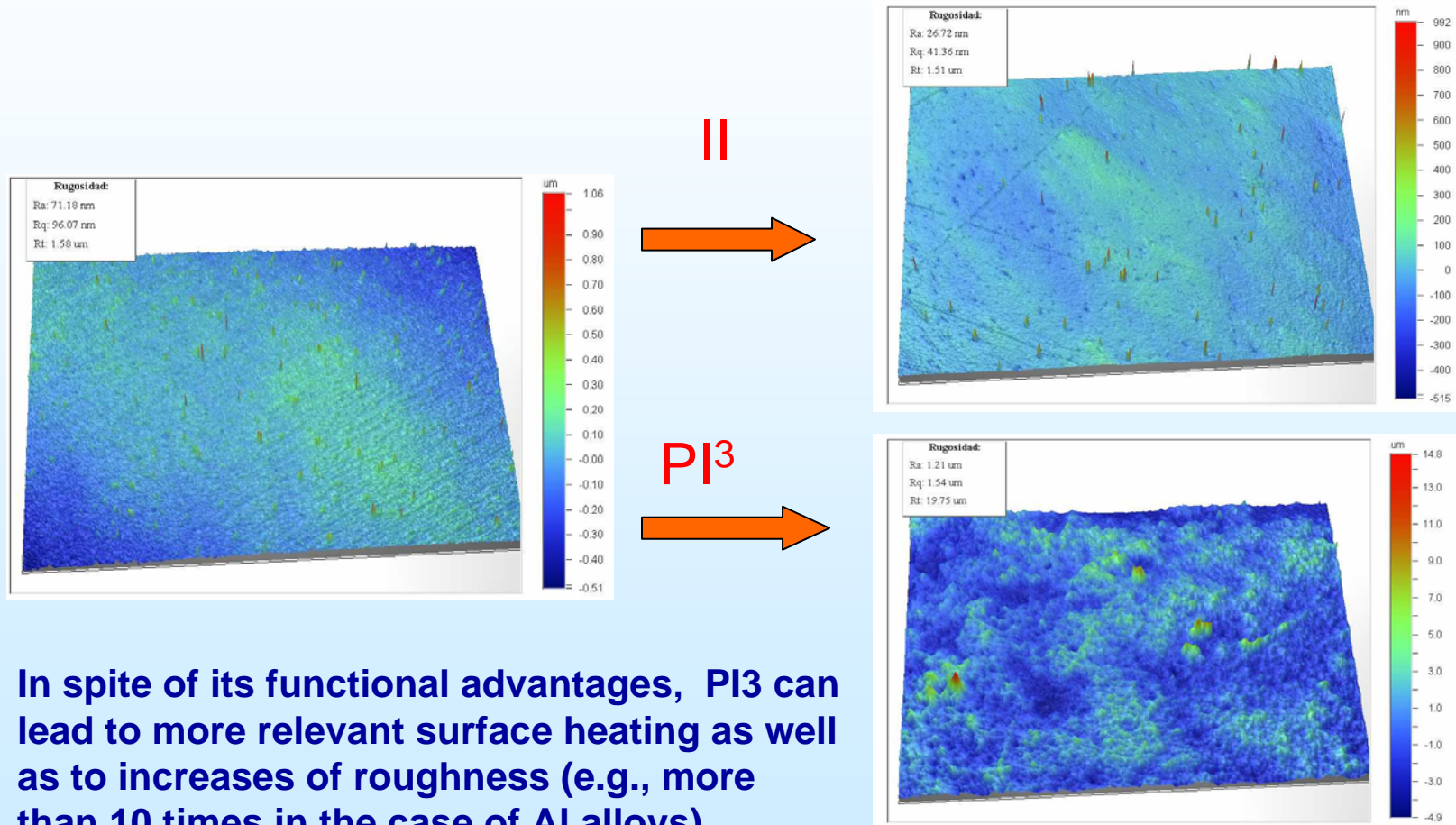
## OXYGEN PLASMA IMMERSION IMPLANTATION ON STEEL



**PI<sup>3</sup> leads to saturated implantation profiles, which goes deeper as a function of the energy.**

**In the case of Oxygen implanted on stainless steel, it can be shown how the oxide barrier confines the Nickel at increasing depth.**

# PLASMA IMMERSION ION IMPLANTATION



In spite of its functional advantages, PI3 can lead to more relevant surface heating as well as to increases of roughness (e.g., more than 10 times in the case of Al alloys)

## FINAL REMARKS

- Ion Implantation has demonstrated to be an effective technique for the prevention of wear, excessive friction and some oxidation and corrosion problems of metal alloys employed in medical implants and devices (stainless steel, Titanium alloys, CrCo, NiTiInol...).
- In addition, other beneficial effects of ion implantation have been reported: implantation of  $\text{CO}^+$  ions seems to facilitate the bone growth and integration. The implantation of  $\text{Ag}^+$  has bacteriocide effects. The implantation of oxygen allows to create difusional barriers for toxic ions...
- The ion implantation treatment of polymers is still more promising, and the required dose is 10 – 20 times smaller.
- Ion implantation is economically affordable when size and geometry collaborate to short times of treatment per unit. Future developments like  $\text{PI}^3$  could lead to even cheaper treatments.

## AIN - Centre of Advanced Surface Engineering

- Private technological center, founded in 1963
- Association of 157 companies
- Employees (2005): 121 (15 AIN - CIAS)
- Clients (2005): 1085 (90 AIN - CIAS)



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